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Microfabrication of gratings for X-ray Imaging

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Introduction

Conventional X-ray radiography relies on the differences in absorption of the constituent of a sample. For biological tissues, polymers or other organic materials, the absorption is so weak that high contrast imaging is very difficult to achieve.

Using the phase shift of X-rays passing through a sample, the image contrast can be significantly enhanced as shown by C. David et al. [1]

The experimental setup being built at our partner institute (Teknologisk Institut) consists of 3 gratings (g0, g1 and g2) as shown below. The analyzer grating g2 as well as the grating g0, raise the most severe fabrication challenges. As opposed to g1 which is made of silicon, g2 and g0 require heavy absorbing material. Often they are fabricated using electrodeposition of gold in a pre-fabricated silicon mould.

Although expensive, gold is an ideal absorber for X-rays and can easily be electroplated. However, to achieve an absorber grating with this conventional method, several fabrication steps must be achieved, hence, increasing the complexity of the overall fabrication process [1][2].

Objectives

A compact and affordable tool to perform non destructive X-ray analysis will be beneficial in the near future. Our objectives is to obtain a good quality grating while focusing on the following points:

- Reproducibility of the fabrication process for industrial large scale fabrication
- Reducing the fabrication complexity by decreasing the number of process steps
- Evaluating the possibilities to pattern cheaper absorbing materials

Grating fabrication using Si mould and Au electroplating

1. Photolithography on Si
2. DRIE of Si using optimized Bosch Process
3. Gold evaporation of gold seed layer
4. Removal of FC layer and resist using Lift-off + Oxygen plasma
5. Gold evaporation back side contact
6. Electroplating

X-ray image of a fish (C. David et al.) (a) in conventional absorption (b) in phase contrast using photon energy 7.5 keV [1]

Tungsten alternative using laser material ablation

Tungsten (W), also known as Wolfram, has the atomic number 74. When compared to gold, W exhibits similar X-ray energy absorption and is significantly cheaper than gold. Therefore, W is an inexpensive alternative grating material. Using laser ablation in air, we have patterned a 7×7 mm grating with a 27 ± 1 µm line width in a 50 µm thick W foil. The grating was characterized using X-ray tomography.

First test of X-ray phase contrast imaging at DTU Physics

- Sketch of the single grating phase contrast setup under development at DTU Physics. The line array grating creates a pattern on the detector. The phase contrast images of a sample can be found from measuring the horizontal (Δx) or vertical (Δy) shift of the projected X-ray pattern when inserting a sample.

Next steps toward Laser Ablation of Tungsten for X-ray gratings

UV wavelength: 355 nm
Tungsten thickness: 50 µm
Beam passes: 220
Mark speed: 200 mm/s
Fluence: 1.2 J/cm²
Line width: 3.1 ± 0.5 mm
Number of pulses: 15000
Fluence: 25 J/cm²
Hole Ø: 11.0 ± 1.5 µm

References